Multiple electrochemically accessible colour states in surface-confined metal-organic monolayers: Stepwise embedding individual metal centres

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Electronic Supplementary Information

The results of selected electrochemical measurements.



Figure S1. CV of Os-Fe stepwise ECM **A)** varying scan rates, **B)** peak current versus scan rate at Fe $E_{1/2}$, **C)** peak current versus root of scan rate at Fe $E_{1/2}$, **D)** peak current versus scan rate at Os $E_{1/2}$, **E)** peak current versus root of scan rate at Se $E_{1/2}$.



Figure S2. CV of Co-Fe stepwise ECM **A)** varying scan rates, **B)** peak current versus scan rate at Fe $E_{1/2}$, **C)** peak current versus root of the scan rate at Fe $E_{1/2}$, **D)** peak current versus scan rate at Co $E_{1/2}$, and **E)** peak current versus root of the scan rate at Co $E_{1/2}$.



Figure S3. CV of Co-Os-Fe stepwise ECM **A)** varying sweep rates, **B)** peak current versus sweep rate at Os-Fe $E_{1/2}$, **c)** peak current versus root of the sweep rate at Fe+Os $E_{1/2}$, **c)** peak current versus sweep rate at Co $E_{1/2}$, and **d)** peak current versus root of the sweep rate at Co $E_{1/2}$.

The results of selected XPS measurements



Figure S4. X-ray photoelectron spectroscopy (XPS) spectra showing the N 1s regions for A) Os-Fe, B) Co-Fe, and C) Co-Os-Fe ECMs

Laviron Kinetics of ECM

CVs at fast scan rates were plotted versus the log of the peak potential (Figure S4-S6) and their slopes determined to give the electron transfer coefficient α :

$$\alpha = \frac{s_a}{\left(s_a - s_c\right)}$$

The electron transport constants (k_{ET}) of materials were calculated form the following formula:

$$\frac{\alpha nFv_c}{k_{\rm ET}} = \frac{(1-\alpha)Fv_a}{RT}$$

where v_a and v_c are the scan rates where the slope intersects the x-axis and the anodic or cathodic branches, respectively. A symmetry exhibited in the Laviron (aka trumpet) plots (Figure S5-S7) is a consequence of transfer coefficient values being close to 0.5.



Figure S5: Laviron plot for Os-Fe stepwise ECMs. At high scan rates, it was impossible to distinguish between the Os and Fe peaks. The constant determined evaluates joint electron rate for Os and Fe species.



Figure S6: Laviron plot for Co-Fe stepwise ECMs: c) Fe and d) Co.



Figure S7: Laviron plot for Fe + Os + Co stepwise ECM at c) Fe and Os, and d) Co.

Table S1. Electron transfer-rate constants of ECM obtained from cyclic voltammetry.

Metal System	k _{ET} (s ⁻¹)					
Sequential	Fe	Os	Со			
Deposition						
Os-Fe	3.3 =	\geq				
Co-Fe	4.6 ± 0.5	\geq	5.3 ± 0.8			
Fe + Os + Co	5.1 =	3.0 ± 0.8				

Table S2. Diffusion coefficient and internal resistance magnitude for the ECMs. $E_{1/2(M)}$ represents the electrochemical potential of the metal in which the constant was determined at.

	$D (cm^2 s^{-1})$			$R_{\Sigma} \left(\Omega^* cm^2 \right)$			
ECM	E _{1/2(Fe)}	E _{1/2(Os)}	E _{1/2(Co)}	E _{1/2(Fe)}	E _{1/2(Os)}	E _{1/2(Co)}	$R_{s}(\Omega^{*}sq)$
Os-Fe	1.1*10-9	1.4*10-9	-	1.5*10 ²	1.3*102	-	164
Co-Fe	2.7*10-9	-	1.1*10-9	1.0*102	-	99	149
Co-Os-Fe	4.4*	10-9	2.0*10-9	79		1.3*10 ²	156

The results of selected spectroelectrochemical measurements.



Figure S8. Spectroelectrochemical results for the Os-Fe stepwise ECM using -1V and +3V holds: **A)** UV-Vis spectra, and durability cycling with 60s holds: **B)** at 515 nm, **C)** at 600 nm, **D)** at 700 nm.



Figure S9. Spectroelectrochemical results for the Co-Fe stepwise ECM using -1V and +3V holds **A)** UV-Vis, and durability cycling with 60s holds: **B)** at 490 nm, **C)** at 600 nm.



Figure S10. Reproducibility test: Chronoabsorptometry of Co-Fe ECDs prepared six month apart by screen printing of different batches of screen-printed paste, followed by depositin of 4-(chloromethyl)phenyltrichlorosilane taken from different bottles, subsequently depositing of metal complexes from different batches and using separately prepared batches of gel electrolyte.